

# Targeting the Mass Production of CVD Graphene

**Zhongfan Liu**

*Beijing Graphene Institute (BGI)*

*Center for Nanochemistry (CNC), Peking University, Beijing 100871, China*

*zfliu@pku.edu.cn*

For graphene industry, mass production of high quality graphene itself is the starting point and finally determines its future. Since 2008, we have been focusing our emphasis on the chemical vapor deposition (CVD) growth of graphene materials. Our work follows two different lines, CVD growth of graphene on metals including Cu, Ni and Cu-Ni alloys, and direct growth on insulators including traditional glass and glass fibers. All the efforts are targeting commercial level mass production together with equipment design and manufacturing. Listed in the following are the current status of our CVD graphene research: (1) 4-6 inch single crystal graphene wafers on Cu(111) and Cu<sub>90</sub>Ni<sub>10</sub>(111)/sapphire, commercial batch production available in 10,000 wafers/year; (2) A3-size graphene films with mm single crystalline domains by static growth, commercially available in 10,000 m<sup>2</sup>/year; (3) A3-size superclean graphene films with CO<sub>2</sub> post-etching technique, commercially available in 10,000 m<sup>2</sup>/year; (4) roll-to-roll graphene films with 20-micrometer single crystalline domains by dynamic growth technique, commercially available in 20,000 m<sup>2</sup>/year; (5) 30 x 30 cm<sup>2</sup> super graphene glass, commercially available in 5000 m<sup>2</sup>/year; (6) graphene-coated glass fibers and fabrics by direct growth technique with a capacity of 5000 m<sup>2</sup>/year. All the CVD systems are home-built with scaling-up capacity for commercialization. The talk will give a brief overview of our over 10-year efforts from fundamentals to mass productions.